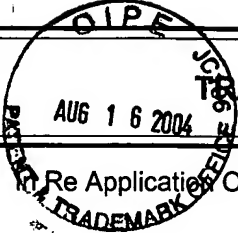

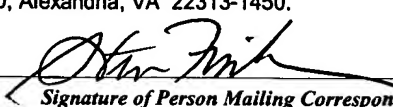


IFW

 TRANSMITTAL OF FORMAL DRAWINGS				Docket No. YOR920030506US1 (17077)	
Re Application Of: Chih-Chao Yang, et al.					
Application No.	Filing Date	Confirmation No.	Examiner	Customer No.	Group Art Unit
10/723,152	November 26, 2003	9245	Unknown	23389	2833
Invention: A PARTIAL INTER-LOCKING METAL CONTACT STRUCTURE FOR SEMICONDUCTOR DEVICES AND METHOD OF MANUFACTURE					
Address to: Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450					
Transmitted herewith are: 13 sheets of formal drawing(s) for this application. <input checked="" type="checkbox"/> Each sheet of drawing indicates the identifying indicia suggested in 37 CFR Section 1.84(c).					
<div style="text-align: center;">  <i>Signature</i> </div> <div style="border: 1px solid black; padding: 5px; margin-top: 5px;"> Steven Fischman Registration No. 34,594 SCULLY, SCOTT, MURPHY & PRESSER 400 Garden City Plaza Garden City, New York 11530 (516) 742-4343 </div>			Dated: August 13, 2004		
<div style="text-align: center;">  <i>Signature of Person Mailing Correspondence</i> </div> <div style="text-align: center; margin-top: 5px;"> Steven Fischman <i>Typed or Printed Name of Person Mailing Correspondence</i> </div>			I certify that this document and attached formal drawings are being deposited on August 13, 2004 with the U.S. Postal Service as first class mail under 37 C.F.R. 1.8 and addressed to the Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.		